

	<b>Hits</b>	<b>Search Text</b>	<b>DBs</b>
43	2	((substrate or wafer) same (LCD or panel\$3 or unit or clich\$2 or area or region or divid\$3) same (groove or etch\$2 or recess\$3 or raise\$2) same pattern\$4) and (((transfer\$3 near4 roll\$4) or (print\$4 near12 (cylinder or roll\$4))) same ((blanket or adhesive or adhesion) near12 (coat\$4 or film or layer)) same (resist or photoresist or (cur\$4 near12 (resin\$4 or material or composition or liquid)))) and (LCD same gate same data same pixel same transistor)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
44	10	((substrate or wafer) same (LCD or panel\$3 or unit or clich\$2 or area or region or divid\$3) same pattern\$4) and (LCD same (gate near4 line) same (pluralit\$4 or multiple) same (data near4 line) same ((pluralit\$5 or multiple) near14 pixel) same (pixel near12 electrode) same transistor) and (print\$4 near8 roll)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
45	12	(LCD same (gate near4 line) same (pluralit\$4 or multiple) same (data near4 line) same ((pluralit\$5 or multiple) near14 pixel) same (pixel near12 electrode) same transistor) and (print\$4 near8 roll)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
46	12	(LCD same (gate near4 line) same (pluralit\$4 or multiple) same (data near4 line) same ((pluralit\$5 or multiple) near14 pixel) same (pixel near12 electrode) same transistor) and (print\$4 same roll)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	<b>Hits</b>	<b>Search Text</b>	<b>DBs</b>
<b>47</b>	86	((substrate or wafer) same (LCD or panel\$3 or unit or clich\$2 or area or region or divid\$3) same pattern\$4) and (LCD same (gate near4 line) same (pluralit\$4 or multiple) same (data near4 line) same ((pluralit\$5 or multiple) near14 pixel) same (pixel near12 electrode) same transistor) and (print\$4)	US_PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB